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(12) **United States Design Patent**
Shinozaki

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(54) **BRUSH FOR CLEANING SEMICONDUCTOR
POLISHING DISK**

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(**) Term: **14 Years**

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(30) **Foreign Application Priority Data**

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(51) **LOC (10) Cl.** **15-05**

(52) **U.S. Cl.**
USPC **D32/25**

(58) **Field of Classification Search**
USPC D4/130, 119, 114, 136, 129, 100, 134,
D4/199; 15/143.1; D30/158; D24/119,
D24/211; D32/25; D25/112
See application file for complete search history.

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(57) **CLAIM**

The ornamental design for a brush for cleaning semiconductor polishing disk, as shown and described.

DESCRIPTION

FIG. 1 is a perspective view of a brush for cleaning semiconductor polishing disk showing my new design;

FIG. 2 is a top view thereof;

FIG. 3 is a front elevation view thereof;

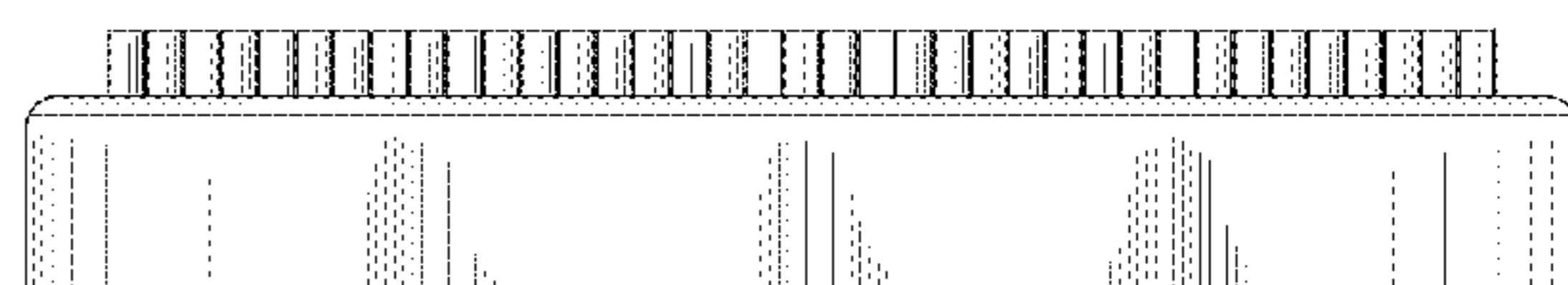
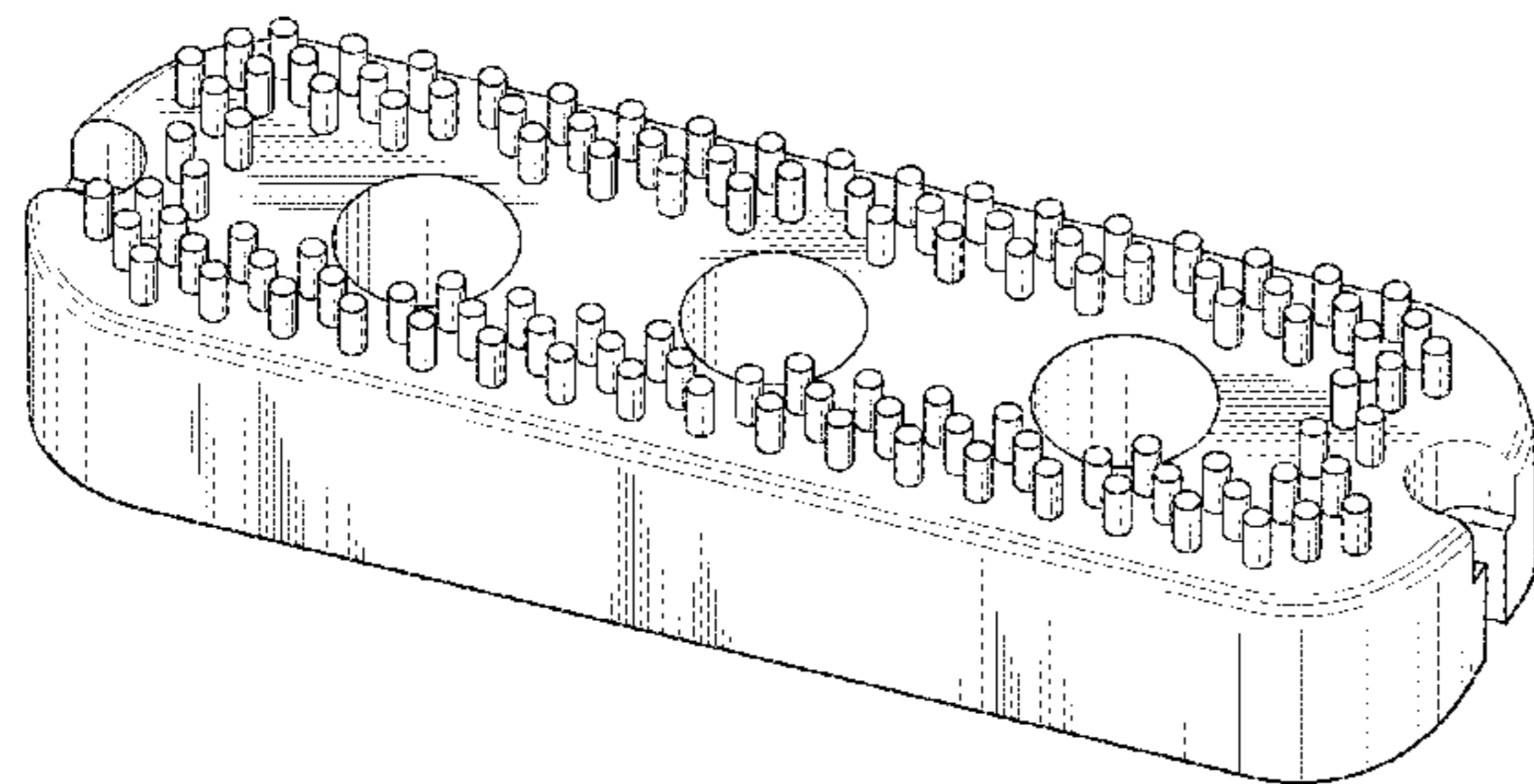
FIG. 4 is a bottom plan view thereof;

FIG. 5 is a right side view thereof; and,

FIG. 6 is a reference view showing a usable state thereof.

The broken line showing is included for the purpose of illustrating environment and forms no part of the claimed design.

1 Claim, 6 Drawing Sheets



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hairbrush-isolated-on-white-background-image-2259785](https://www.colourbox.com/image/bath-anti-cellulitis-spa-massage-kit-with-comb-brush-and-hairbrush-isolated-on-white-background-image-2259785).*

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FIG. 1

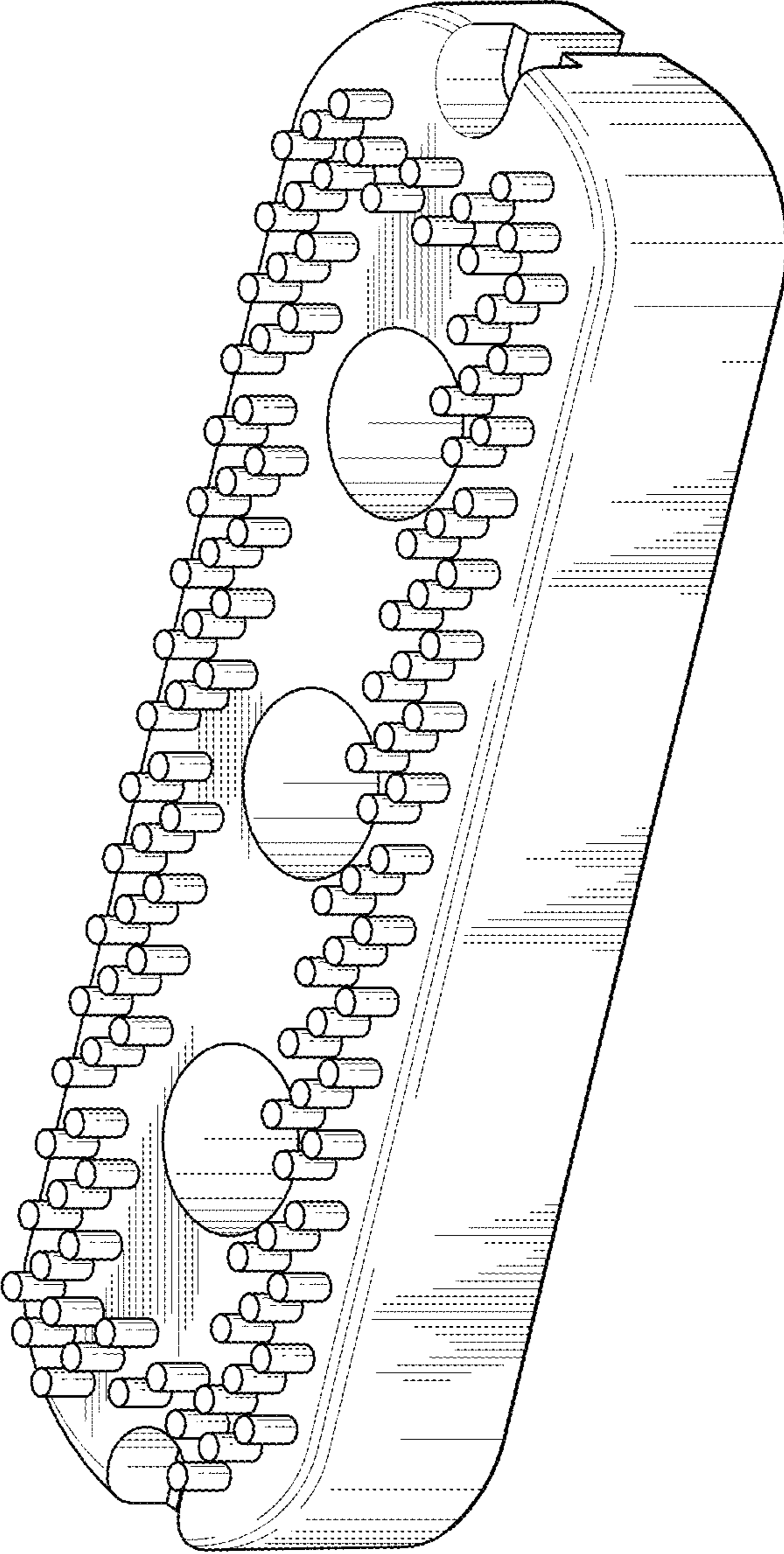


FIG. 2

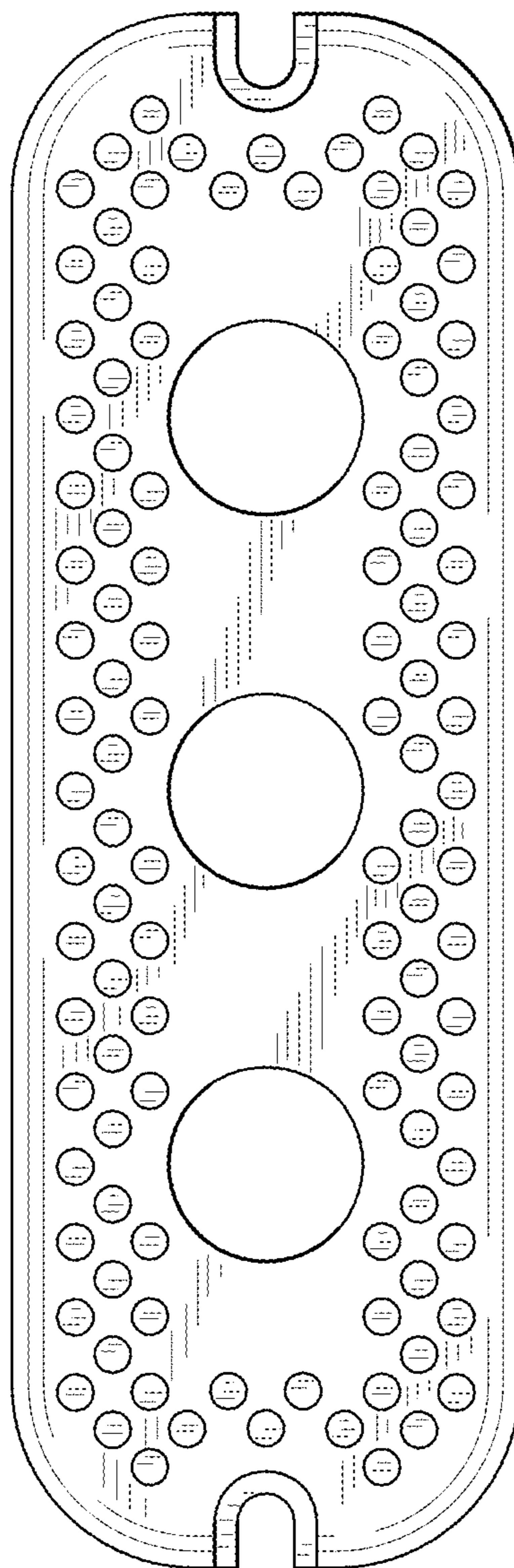


FIG. 3

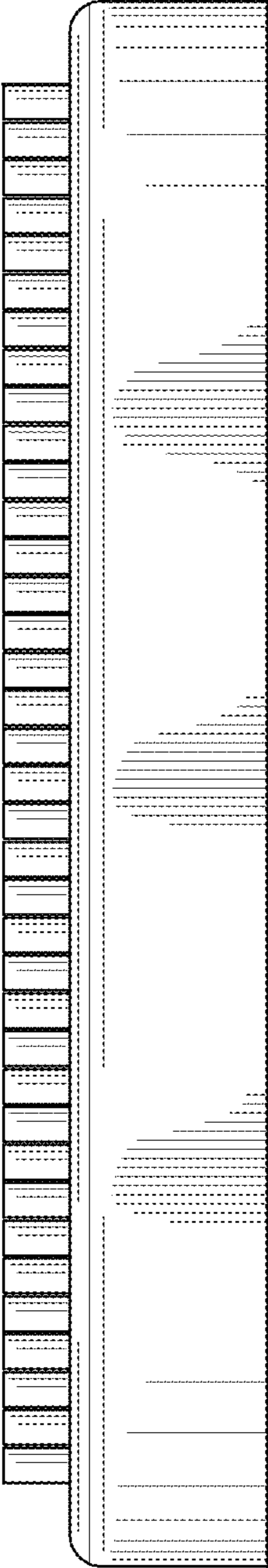


FIG. 4

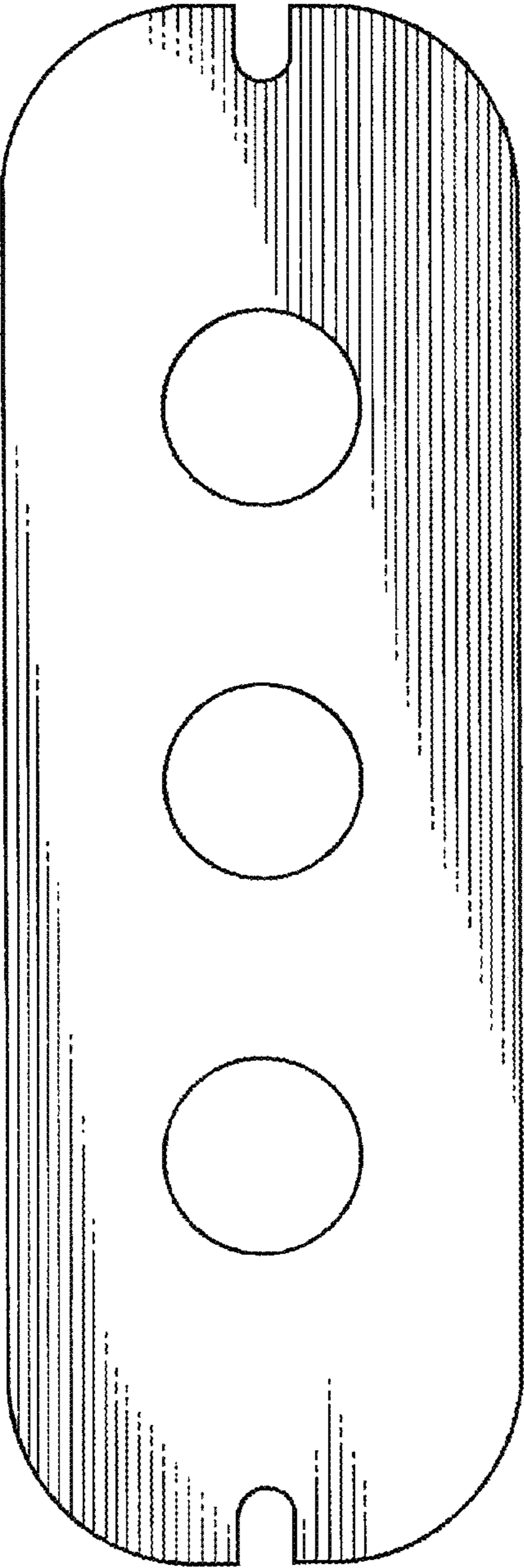
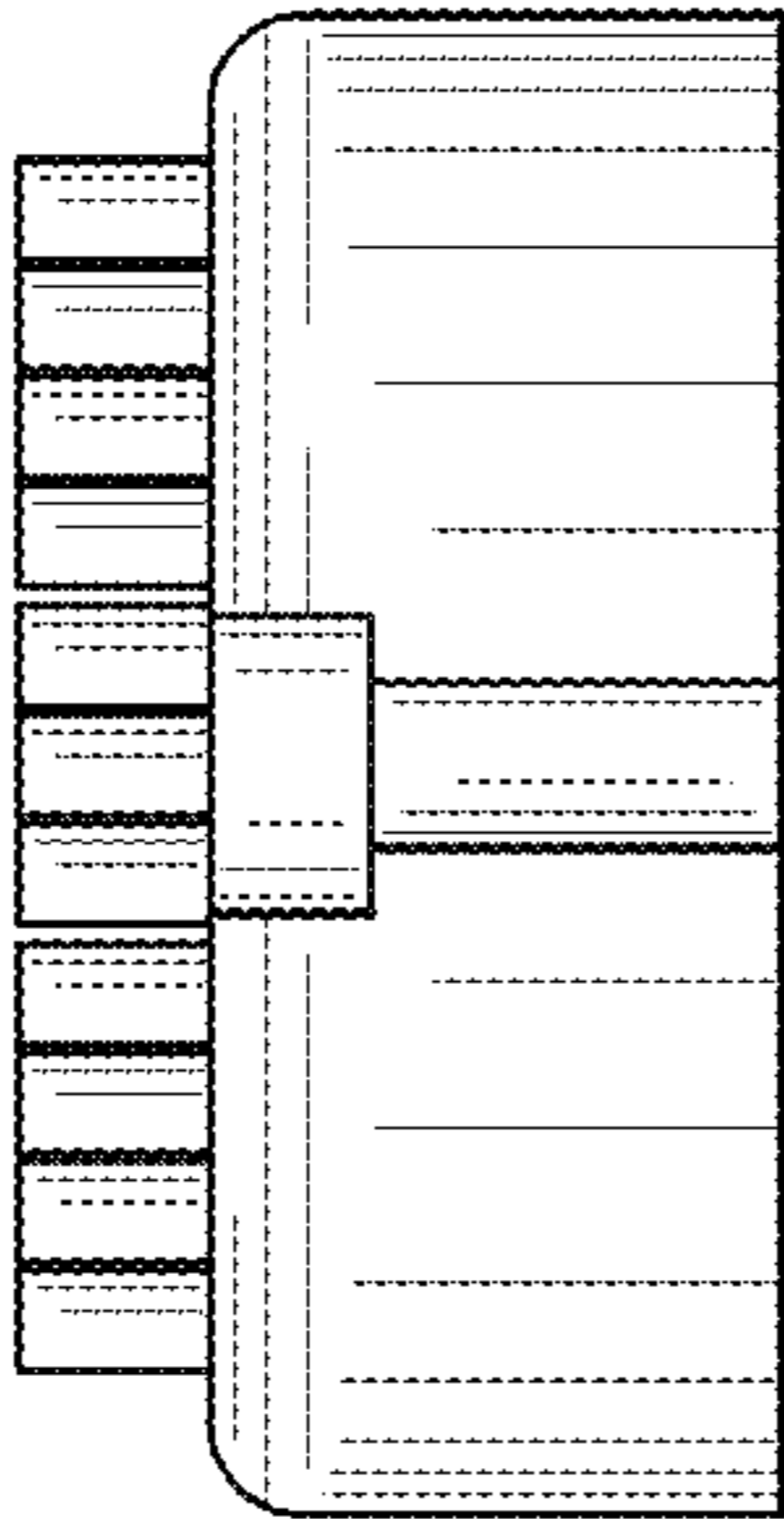


FIG. 5



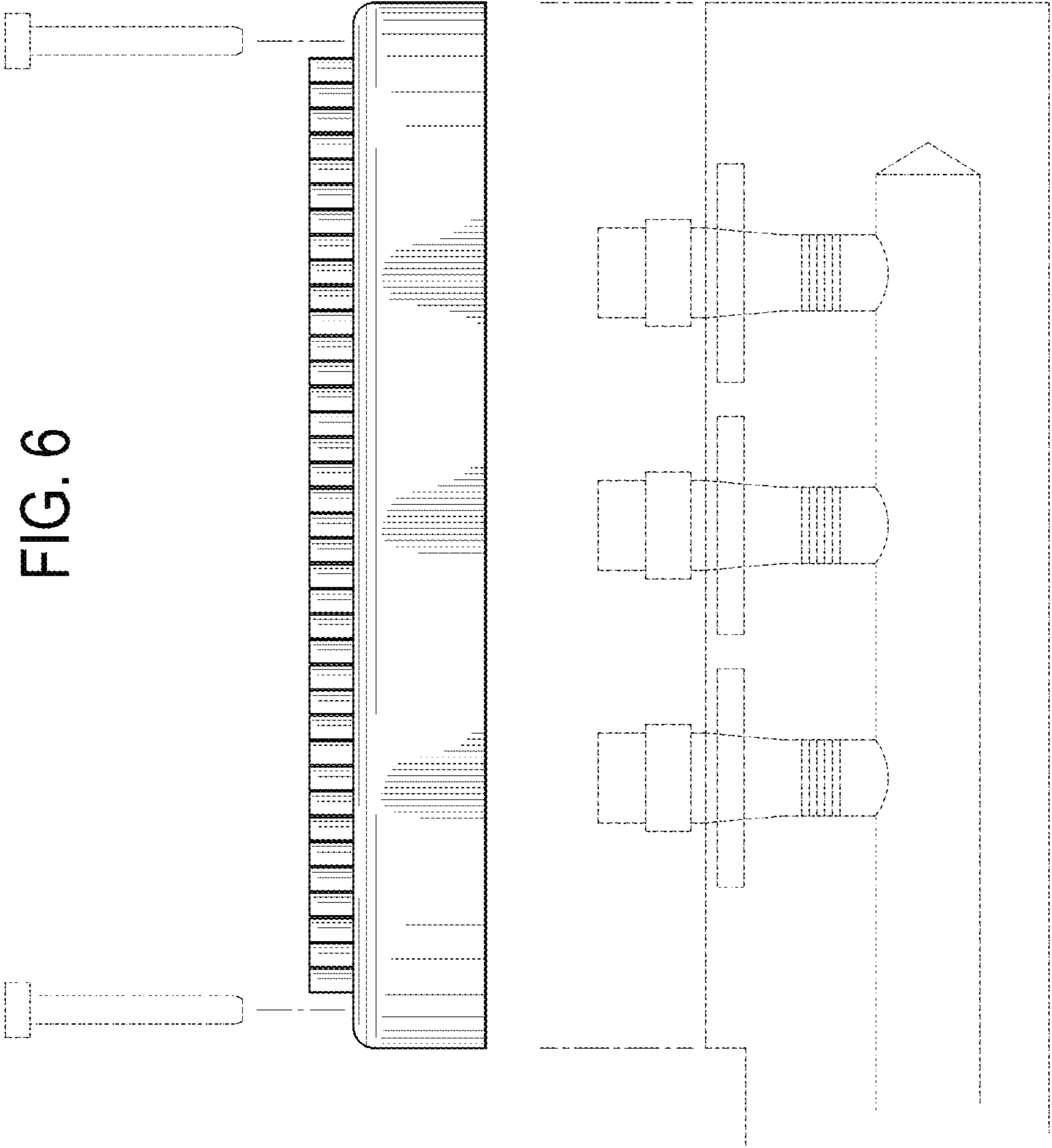


FIG. 6